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Notice of Allowability	Application No.	Applicant(s)	
	10/634,824	ARITA, TOSHIYUKI	
	Examiner	Art Unit	
	William M. Brewster	2823	
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.			
1. This communication is responsive to <u>17 December 2004</u> .			
2. ☑ The allowed claim(s) is/are <u>1-18</u> .			
3. The drawings filed on <u>06 August 2003</u> are accepted by the Examiner.			
 4. Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b)			
Attachment(s) 1. ☑ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948) 3. ☐ Information Disclosure Statements (PTO-1449 or PTO/SB/O Paper No./Mail Date	5. ☐ Notice of Informal Pa 6. ☐ Interview Summary (Paper No./Mail Date 8), 7. ☒ Examiner's Amendm 8. ☒ Examiner's Statemen 9. ☐ Other	(PTO-413), e nent/Comment	

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EXAMINER'S AMENDMENT

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

The application has been amended as follows:

a) In the Title

In the title: After, "Method", insert, --Forming a Resist Pattern, a Film Over the Resist, and Reflowing the Resist--

Reasons for Allowance

The following is an examiner's statement of reasons for allowance: in claim 1, lines 4-11, forming a film over the resist, spatially define sidewall surfaces of the resist pattern, reflowing the resist using the film to restrict the resist, removing the film, can not be found in the prior art of record. The prior art of record fails to teach, in combination, the process features.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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Any inquiry concerning this communication or earlier communications from the

examiner should be directed to William M. Brewster whose telephone number is 571-

272-1854. The examiner can normally be reached on Full Time.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Olik Chaudhuri can be reached on 571-272-1855. The fax phone number

for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the

Patent Application Information Retrieval (PAIR) system. Status information for

published applications may be obtained from either Private PAIR or Public PAIR.

Status information for unpublished applications is available through Private PAIR only.

For more information about the PAIR system, see http://pair-direct.uspto.gov. Should

you have questions on access to the Private PAIR system, contact the Electronic

Business Center (EBC) at 866-217-9197 (toll-free).

1 February 2005

WB

Olik Chaudhuri Supervisory Patent Examiner Technology Sector 2800

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